<u>崩壊分岐比感度 10⁻¹⁵の</u> 新しい μ+ → e+γ 探索 実験の検討

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東大ICEPP,東大理^A, PSI^B 内山雄祐, 家城佳^B,岩本敏幸,大谷航,小川真治^A,金子大輔^A,澤田龍,柴田直哉^A, 中浦正太^A,西村美紀^A,森俊則,吉田昂平^A, Elisabetta Baracchini

<u>Abstract</u>

- A project to make a new muon beamline is progressing at PSI to provide 10–100 times higher continuous muon beam.
- 2. Study possibilities of carrying out a new $\mu \rightarrow e\gamma$ experiment with a sensitivity of 10^{-15} , an order of magnitude better than MEG-II.
- 3. Consider **converting photon spectrometer** for the gamma-ray detector.



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<u>HiMB project</u>



• Next generation High Intensity Muon Beam project



$\mu \rightarrow e\gamma$ status (from MEG to MEG II)

MEG completed data taking

- Set limit $\mathscr{B}(\mu \rightarrow e_{\aleph}) < 5.7 \times 10^{-13}$ @90%CL
- Final result with ~40% improved sensitivity coming soon.

MEG II construction has been started

- Aim at x10 better sensitivity (< 5x10⁻¹⁴)
- By exploiting full beam intensity available today $\cdot \sim \! 10^8 \, \mu^+\!/s$ at the PSI $\pi E5$
- By upgrading the MEG detector
 - Keep experimental concept
 - In short (~5 years), at low cost

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<u>Next decade</u>





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MEG experiment



MEG features

1. Liquid xenon γ detector

- \bigcirc High eff. γ detection (ϵ > 50%)
- Total absorption w/o any dead material, with good uniformity and high light yield ($\sigma_{\rm E} \sim 1\%$)
- \bigcirc High time resolution ($\sigma_t \sim 60 \text{ ps}$)
- imes Difficult operation, need massive cryostat
- imes Weak to pileup due to single volume
- imes No power of direction reconstruction
- 2. Gradient B-field for efficient e⁺ measurement
- Relatively small solid angle (geometrical acceptance) ~ 10%

From MEG II

• To improve x10 (a few dozens?) sensitivity, we need at least x10 statistics. How to gain?

Higher beam intensity × 3, 5, 10, 100 ?

MEG II $7 \times 10^7 \,\mu^+/s$

Increase acceptance × 3, 5, 10 ?

MEGII~5%

Then, we have to reduce increased BG.

– How much do we have to reduce?

Statistics & BG

$$N_{BG} \propto \left(R_{\mu}\right)^{2} \cdot \epsilon \cdot \delta E_{e} \cdot \left(\delta E_{\gamma}\right)^{2} \cdot \left(\delta \vartheta_{e\gamma}\right)^{2} \cdot \left(\delta t_{e\gamma}\right)$$

E	<u>Statistics & BG</u>								
	$N_{BG} \propto \left(R_{\mu}\right)^{2} \cdot \epsilon \cdot \delta E_{e} \cdot \left(\delta E_{\gamma}\right)^{2} \cdot \left(\delta \vartheta_{e\gamma}\right)^{2} \cdot \left(\delta t_{e\gamma}\right)$								
	S: Increas B: Increas	rease factor of the statistics ($\propto R_\mu \cdot \epsilon$) crease factor of number of BG events ($\propto N_{BG}$)							
Þ		εх1		εх3		ε x 5		εx 10	
Ľ		S	В	S	В	S	В	S	В
e	Rµ x 1	MEG	II	3	3	5	5	10	10
F	Rµ x 3	3	9	9	27	15	45	30	90
G	Rµ x 5	5	25	15	75	25	125	50	250
Ľ	Rµ x 10	10	100	30	300	50	500	100	1000
e	Rµ x 100	100	10000	300	30000	500	50000	1000	10 ⁵
					*	Assuming	same run	ning time	as MEG II

<u>Converting Photon</u> <u>Spectrometer</u>

<u>Concept</u>

0.045 X0

- Measure e⁺e⁻ pair from incident photon converted in conversion layer.
- Previous experiment, MEGA, used this type detector.
- Merits
 - Good <u>position</u> resolution
 - <u>Direction</u> of γ reconstructed
 - Strong against pileup
 - Low cost (?)
 - Better <u>energy resolution</u> possible but trade off b/w efficiency
- Challenge: How to gain efficiency
 - ~a few %
 - Complicated pattern recognition and tracking



FIG. 5. A cross section of a pair spectrometer layer, showing the aluminum support cylinder for an inner layer, and the timing scintillators, conversion cylinders, MWPC and drift detectors for the next outer layer. A typical conversion in the first conversion cylinder is shown.



Preceding studies

arXiv 1309.7679 & Snowmass 2013 report

- There are a few preceding studies of new μ→eγ experiments using the converting photon spectrometer.
 - Mainly in US snowmass process for ProjectX
 - They conclude that it is possible to go to O(10⁻¹⁵)

However, there are several points suspicious

- Unreasonable assumptions,
- Not proper (or lack) simulation





A o.56 mm Pb (0.1 Xo) conversion layer. Si strip for detector



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Resolution vs Thickness

Perform simple MC study

- shoot 52.8 MeV γ perpendicular to the Pb plate
- Calculate out-coming e+e- energies
- Need to track particle as low as <10 MeV to get good efficiency



(dominant) was not simulated!



Energy reso. is limited by energy loss in converter

- Energy loss clearly correlates with path length inside the converter
- However, reconstruct the depth of conversion seems difficult
- As thin as 100 um necessary.
- Efficiency is <0.75% per layer.



- Able to solve the dilemma by sub-layers
 - Fill the gap with active device, or
 - Just gap
 - can disentangle sub layer



y angular resolution



γ direction can be reconstructed from momenta of the pair

- **Resolution: ~50 mrad** (<10 mrad in ProjectX study)
 - Limited by multiple scattering in the converter
 - Similar to MEGA's resolution (250 um Pb)

Possible configuration

- In 1.5 T <u>uniform</u> B-field
- 10 super layers
 - first layer from r=26 cm
 - at 5 cm radial distance

• A super layer consists of

- two 100 um Pb converters
- two Si pixel layers put both outside the conversion double layer

Target

- 100 um plastic sheet
- slant angle of 10° to spread vertex distribution
- □ ~15% conversion eff. assuming 50% rec. eff. ⇒ 7–8% eff.

Need active area of 160 m² CMS level!

⇒ Increase B-field, increase sub-layers

Detector requirement

Si pixel tracker with

- Large area
- High time resolution (O(100 ps))
- Ultra thin (~50 um)
 - If build e⁺ side as well, <50 um important

No available device today

Need device development



<u>Summary</u>

Toward $\mu \rightarrow e\gamma$

O(10)

In times larger statistics achievable by

- 5 times higher intensity beam
- twice higher signal acceptance (compared to MEG II)
- with multi-layer converting photon spectrometer
 - multi layers to gain efficiency
 - sub layers for good resolution retaining efficiency

Suppress increased BG by

- Vertex matching (compensate increased beam rate)
- Better γ energy resolution (3 times better)

However, realization seems really challenging

- Need further detailed studies
- Need technological development
- Need more or completely different idea

To be studied

- Reconstruction (pattern recognition & tracking)
- Event overlap
- BG study

e⁺ side (no study yet)



Double beam intensity,
Double efficiency,
Suppress BG factor ~30
Halve every resolution,
Add new detector to identify BG (option) Keep 3 keys of MEG

- 1. World's most intensity DC μ beam @ PSI
- 2. Innovative liquid xenon γ -ray detector
- 3. Gradient B-field e⁺-spectrometer

TABLE XI: Resolution (Gaussian σ) and efficiencies for MEG up						
PDF parameters	Present MEC	G Upgrade sce				
e ⁺ energy (keV)	306 (core)	130				
$e^+ \theta$ (mrad)	9.4	5.3				
$e^+ \phi$ (mrad)	8.7	3.7				
e^+ vertex (mm) Z/Y (core)	2.4 / 1.2	1.6 / 0.7				
$\gamma \text{ energy } (\%) \ (w < 2 \text{ cm})/(w > 2 \text{ cm})$	n) 2.4 / 1.7	1.1 / 1.0				
γ position (mm) $u/v/w$	5/5/6	2.6 / 2.2 / 5				
γ -e ⁺ timing (ps)	122	84				
Efficiency (%)						
trigger	≈ 99	≈ 99				
γ	63	69				
e ⁺	40	88				
muon rate	3.3x10 ⁷ /sec	7x10 ⁷ /sec				
		Timing counter				
	Now	199				
		positron spe				

Detector technology

- Ultra thin device necessary to suppress multiple scattering.
- HV-MAPS
 - Thinned down to 30–50 μm
 - Amp, digitization on chip
 - Fast readout: <50 ns timestamp





(High voltage monolithic active pixel sensors) I. Peric et.al. NIMA 582 (2007) 876



- - HV-MAPS
 - Flex print
 - Kapton Frame -

<1‰ X_o per layer

Mock-up

<u>Mu3e Experiment</u>

Tackle with new technologies

100cm



SciFi σ_t ~ a few 100 psec

Cone-shape target disperse vertices into large surface

Geometrical acceptance ~70%



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HV-MAPS Prototypes

Design Specifications

- 80 μm \times 80 μm pixel size
- $1 \text{ cm} \times 2 \text{ cm}$ active area

MuPix2

- 39 μm \times 30 μm pixel size
- $1.8 \,\text{mm} \times 1 \,\text{mm}$ active area
- Proof of Concept

MuPix3/4

- $92\,\mu m \times 80\,\mu m$ pixel size
- 2.9 mm \times 3.2 mm active area

MuPix4 HV-MAPS Prototype



- 92 μm \times 80 μm pixel size
- Global threshold
- Zero-suppressed digital readout
- Timestamps
- Additional readout FPGA





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Yusuke UCHIYAMA/